



GE
Global Research

One Research Circle
Niskayuna, New York 12309
USA

GE Global Research

GE Global Research is one of the world's most diversified industrial research organizations, providing innovative technology for all of GE's businesses. Global Research has been the cornerstone of GE technology for more than 100 years, and is now focused on developing breakthrough innovations in areas such as molecular medicine, alternative energy, nanotechnology, advanced propulsion and security technologies. GE Global Research is headquartered in Niskayuna, New York and has facilities in Bangalore, India; Shanghai, China, and Munich, Germany.

Every day we push technology to its limits to drive growth for the GE businesses and improve the world around us. Our long-range research programs create the breakthrough technologies that create differentiation for GE products and services and win in our markets.

For any industrial lab, technical diversity is key. GE's diverse set of businesses naturally creates the most diverse industrial lab in the world. From aircraft engines to power generation to our financial businesses and even our television network and movie studios, GE Global Research can leverage technology across industries and across scientific disciplines. Our strength lies in our robust set of core technologies and how we apply our breakthroughs to our businesses. We live by the mantra: "What we can imagine, we can make happen."

Quick Facts

Headquarters:	Niskayuna, New York (550-acre site)
Global Locations:	Bangalore, India (John F. Welch Technology Centre) Shanghai, China (China Technology Center) Munich, Germany (GE Global Research – Europe)
Employees:	~2,800 Worldwide (Nearly 1,000 PhDs)
Leadership:	Mark Little, Senior Vice President, GE Global Research
R&D Budget:	GE Total 2008: ~\$4.3 billion GRC Total 2008: \$555 million
U.S. Patents:	2008 GE Total: 2,537 (filed) 2008 GE Global Research: 560 (filed)
Web Site:	www.ge.com/research www.grcblog.com - GE Technology Blog